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Weak field galvanomagnetic measurements
to distinguish cubic from non-cubic environments

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Résumé. — Des procédures qui utilisent une extension de la technique Van der Pauw sont développées pour
distinguer, par des mesures galvanomagnétiques de champ faible, des symétries cubiques et non cubiques. Nous
considérons les couches orientées (001), (110) et (111) pour lesquelles les expressions analytiques sont données.
Des échantillons plats, en forme de cercle peuvent être utilisés. Nous avons aussi trouvé que, en général, quand
\( \mathbf{B} = (B_u, B_v, B_w) \) un comportement de torsion est attendu, tel que, les directions principales de la surface
de résistivité et les axes crystallographiques se trouvent dans des directions différentes.

Abstract. — Procedures utilizing an extension of the Van der Pauw technique are developed to distinguish by weak
field galvanomagnetic measurements cubic and non-cubic symmetries. We consider (001), (110) and (111) oriented
layers for which analytic expressions are given. Planar circular samples may be used. We have also found that
in general when \( \mathbf{B} = (B_u, B_v, B_w) \) a skewed behaviour is expected such that the principal directions of the surface
of the resistivity magnitude and the crystallographic axes lie in different directions.

1. Introduction. — Under weak field conditions
the relation between the electric field \( \mathbf{E} \) and the current
density \( \mathbf{J} \) in the presence of a magnetic field \( \mathbf{B} \) may
be expressed as [1]

\[
E_i = \rho_{ij} J_j + \rho_{ijk} J_j B_k + \rho_{ijkl} J_j B_k B_l + \cdots, \tag{1}
\]

where the galvanomagnetic (GVM) coefficients \( \rho_{ij} \),
\( \rho_{ijk} \) and \( \rho_{ijkl} \) are tensor elements of the zero field
resistivity, the weak field Hall coefficient (WFHC)
and the weak field magnetoresistance (WFMR). In (1)
the implied summation is carried over all possible
values of all repeated indices. Recently Allgaier et al. [2-5] have developed an extension of the Seitz-
Pearson-Suhl [6] magnetoresistance formula applicable
to (001) and (111) oriented layers in a situation
where it has not been determined that the environ-
ment is, in fact, cubically symmetric. They showed
how four WFMR measurements could be made on a
single sample in either orientation, making it possible
to distinguish between cubic and tetragonal environ-
ments in the first case, and among cubic, trigonal, and
hexagonal ones in the second orientation.

In the present paper, we develop procedures for
utilizing an extension [7] of the Van der Pauw tech-
nique [8] to distinguish cubic and non-cubic symmetries
from weak-field galvanomagnetic measurements. We
consider (001), (110) and (111) oriented layers.

In the case of cubic crystals [groups \( \text{Oh} (m3m), \text{O} (432) \) and \( \text{Td} (43 m) \)], five different weak-field GVM
coefficients need to be determined, namely

\[
\rho_0, \rho_{123}, \rho_{1111}, \rho_{1122} \quad \text{and} \quad \rho_{1212}. \tag{2}
\]

Thus the zero field resistivity \( \rho_0 \) and the WFHC \( \rho_{123} \)
are isotropic, while the relative values of the three
WFMR coefficients are related to the types of band-
structure and scattering anisotropies which can occur
within the framework of cubic symmetry.

2. The measuring principles. — The measurements
are based on Wasscher's extension [7] of the method
of Van der Pauw [8] to the case of crystals with an
anisotropic resistivity. He describes how this extension
might be applied to magnetoresistance measurements,
i.e., to a magnetic-field induced resistivity anisotropy.
We use a planar, circular sample with four contacts
ABCD taken along the circumference on two perpen-
Wasscher discusses the advantages of this configuration. We may then define the resistances

\[ R_1 = \frac{V_D - V_C}{I_{AB}}, \quad R_2 = \frac{V_A - V_D}{I_{BC}}, \]

and

\[ R_{12} = \frac{V_A - V_C}{I_{BD}}. \] (3)

The maximum value of the resistance ratio,

\[ \frac{(R_1/R_2)_{\text{max}}}{(R_1)_{\text{max}}/(R_2)_{\text{min}}}, \]

is obtained when the contacts are placed at an angle of 45° to the directions of the principal axes of resistivity \( \rho_1 \) and \( \rho_2 \), with resistivities \( \rho_{11} = \rho_1 \) and \( \rho_{22} = \rho_2 \) correspondingly (\( \rho_1 > \rho_2 \)). This ratio is related to the anisotropy ratio \( \lambda = \rho_1/\rho_2 \). For the principal axis resistivities in the plane of the sample, we have [9]

\[ \rho_1 = \frac{\lambda^{1/2} \pi d (R_{1})_{\text{max}}}{\ln \frac{2}{1 - k}}, \] (4)

and

\[ \rho_2 = \frac{\lambda^{-1/2} \pi d (R_{2})_{\text{min}}}{\ln \frac{2}{1 + k}}. \] (5)

where \( d \) is the thickness and \( k \) is the modulus of the elliptic integral that is related to the ratio \( \lambda \) [7, 9].

It should be mentioned here, that the above technique gives the same results as two independent measurements in the case of the classical procedure with \( \bar{J} \) lying first in the \( x_1 \) direction and the other in the \( x_2 \) direction. In fact, from eq. (3) and figure 1 it is evident that the resistances \( (R_1)_{\text{max}} \) and \( (R_2)_{\text{min}} \) are defined with \( \bar{J} \) lying in the directions \( x_1 \) and \( x_2 \) respectively.

The Hall coefficient in this method, for a field perpendicular to the plane of the sample, is determined from the relation [8]

\[ R_H = \frac{d}{B} \Delta R_{12}, \] (6)

where \( \Delta R_{12} \) is the change in the resistance \( R_{12} \) due to the presence of the magnetic field.

As it is well known [10], if the direction cosines of \( \bar{J} \) and \( \bar{B} \) are \( p, q, r \) and \( u, v, w \), respectively, then the zero-field resistivity in the direction of \( \bar{J} \) is

\[ \rho(0) = \frac{\bar{E} \cdot \bar{J}}{J^2} = \rho_0 p^2 + \rho_0 q^2 + \rho_0 r^2 = \rho_0, \] (7)

while in the presence of the magnetic field \( \bar{B} \) we have

\[ \rho(\bar{B}) = \frac{\bar{E}(\bar{B}) \cdot \bar{J}}{J^2} = \]

\[ = \frac{[\rho_0 + (\rho_{1111} u^2 + \rho_{1122} v^2 + \rho_{1122} w^2) B^2] p^2}{J^2} \]

\[ + \frac{[\rho_0 + (\rho_{1212} u^2 + \rho_{1111} v^2 + \rho_{1122} w^2) B^2] q^2}{J^2} \]

\[ + \frac{[\rho_0 + (\rho_{1122} u^2 + \rho_{1111} v^2 + \rho_{1111} w^2) B^2] r^2}{J^2} \]

\[ + 4 \rho_{1112} B^2 \frac{[u wpq + v wqr + w r pu]}{J^2}. \] (8)

Comparing the two eqs. (7) and (8), we conclude that the presence of magnetic field introduces an anisotropy in the specific resistivity such that its principal axes and the crystallographic axes, in general, lie in different directions [11]. The corresponding effect is known as magnetoresistance skewness [2, 12].

3. Sample parallel to the (001) plane. — In this case the sample plane contains the two axes \( x_1 \) and \( x_2 \), and we have \( \bar{J} = (J \cos \omega, J \sin \omega, 0) \) (Fig. 2). To obtain the GVM coefficients we perform measurements in the following manner.

\[ \rho_0 = \frac{\pi d}{\ln 2} \frac{R_1 + R_2}{2 f(R_1/R_2)} \] (9)

\[ \rho_0 = \frac{\pi d}{\ln 2} \frac{R_1 + R_2}{2}. \]
because for the contacts at right angles, \( R_1 = R_2 \), and the corrective factor is \( f(1) = 1 \).

3.2 Hall Coefficient. — When \( \vec{B} = (0, 0, B) \), the components of the electric field are

\[ E_1 = \rho_{123} J_2 B \], \( E_2 = -\rho_{123} J_1 B \) and \( E_3 = 0 \).

Thus \( |\vec{E}_H| = \rho_{123} J B \) and \( \rho_{123} \) is determined from eq. (6).

3.3 WFMR Coefficients. — Two configurations will be treated:

a) \( \vec{B} = (B, 0, 0) \). Using figure 2 and eq. (8) we obtain

\[ \rho(\vec{B}) = (\rho_0 + \rho_{1111} B^2) \cos^2 \omega + (\rho_0 + \rho_{1122} B^2) \sin^2 \omega \]  

(11)
corresponding to a resistivity anisotropy with principal axes lying in the crystallographic directions \( x_1 \) and \( x_2 \) (Fig. 3). By measuring the experimental quantities \( \rho_0, \rho_{11}(\vec{B}) \) and \( \rho_{22}(\vec{B}) \), we obtain

\[ \Delta \rho = \rho_{1111} B^2 \cos^2 \omega + \rho_{1122} B^2 \sin^2 \omega \]  

(12)
where

\[ \Delta \rho_{11} = \rho_{11}(\vec{B}) - \rho_0 \], \( \Delta \rho_{22} = \rho_{22}(\vec{B}) - \rho_0 \).  

(13)

Thus we are led to the relations

\[ \rho_{1111} = \frac{\Delta \rho_{11}}{B^2} \]  

and \( \rho_{1122} = \frac{\Delta \rho_{22}}{B^2} \)  

(14)
by which \( \rho_{1111} \) and \( \rho_{1122} \) may be determined from experimental measurements of \( \Delta \rho_{11} \) and \( \Delta \rho_{22} \). It is evident that, with the above direction of \( \vec{B} \), \( \Delta \rho_{11} \) corresponds to the longitudinal magnetoresistance while \( \Delta \rho_{22} \) corresponds to the transverse one [13], as stated previously in connection with the defining eqs. (4) and (5). It should be noted here that in the case of \( \vec{B} = (0, B, 0) \), the same anisotropy appears with a phase difference of \( 90^\circ \) so that the same two WFMR coefficients, \( \rho_{1111} \) and \( \rho_{1122} \), are obtained, but in reverse order. Finally for \( \vec{B} = (0, 0, B) \) the sample remains isotropic and only the coefficient \( \rho_{1122} \) can be determined.

This last case is interesting when we have (001)-oriented films or surface layers. Suppose that the value of \( \rho_{1122} \), as determined from this configuration is different from that determined by eq. (14). This result is an indication of tetragonal, rather than cubic symmetry, with the tetragonal axis lying along the [001] direction [4].

b) \( \vec{B} = (B_u, B_v, 0) \). In this case an anisotropic (skewed) behaviour is expected, such that the principal axes and the crystallographic axes lie in different directions (Fig. 4): If these directions are at an angle \( \phi \) to each other then the following equation is valid (see appendix)

\[ 4 \rho_{2122} B^2 u v = \sin 2 \phi [\rho'_{11}(\vec{B}) - \rho'_{22}(\vec{B})] \]  

(15)

where \( \rho'_{11}(\vec{B}) \), \( \rho'_{22}(\vec{B}) \) are the principal resistivities under the influence of the magnetic field. In this way, the coefficient \( \rho_{1122} \) is obtained. The procedure is to choose first a certain direction of \( \vec{B} \) with respect to the \( (x_1, x_2) \) set of axes and then rotate the system of contacts, without changing the direction of \( \vec{B} \), until the maximum value of \( R_1/R_2 \) is found; thus the value of the angle \( \phi \) and the resistances \( \rho'_{11}(\vec{B}) \) and \( \rho'_{22}(\vec{B}) \) are obtained.

Eq. (15) leads to a new definition of the \( \rho_{i,j} \) coefficient. Thus for \( u = v = 1/\sqrt{2} \) we have

\[ \rho_{i,j} = \frac{1}{2} B^2 \sin 2 \phi [\Delta \rho'_{i}(\vec{B}) - \Delta \rho'_{j}(\vec{B})] \]  

(16)

where \( \Delta \rho'_{i}(\vec{B}) = \rho'_{i}(\vec{B}) - \rho_0 \) and \( \Delta \rho'_{j}(\vec{B}) = \rho'_{j}(\vec{B}) - \rho_0 \). Therefore the \( \rho_{i,j} \) coefficient expresses the difference between the two principal magnetoresistances and the imposed skewness by the magnetic field.
4. Sample parallel to the (110) plane. — In the case that the specimen is parallel to a (110) plane as in the case of thin films grown on (110) substrates, a new set of axes should be chosen in terms of which the measurements may be defined. We use the coordinate system \([110] = x_1', [110] = x_2', [001] = x_3'\) (Fig. 5). With this set, the plane of the sample contains the \(x_1'\) and \(x_3'\) axes. Axes \(x_1\) and \(x_2\) exhibit two-fold, and \(x_3\), four-fold rotational symmetry. These axes are similar to the axes of the tetragonal system for the groups \(D_4(422), C_{4v}(4mm), D_{2d}, V_d(42m),\) and \(D_{4h}(4/mmm)\).

Fig. 5. — The coordinate system in the case of a sample parallel to the (110) plane.

The resistivity and Hall coefficients for these groups involve the four different nonzero tensor elements [13]

\[
\rho_{11} = \rho_{22}, \rho_{33}, \rho_{123} \text{ and } \rho_{231}(= \rho_{312}), \tag{17}
\]

while the nonzero WFMR coefficients are presented in table I, using the following correspondence :

\[
\begin{align*}
11 & \rightarrow 1 \quad 22 \rightarrow 2 \quad 33 \rightarrow 3 \\
23 & \rightarrow 4 \quad 31 \rightarrow 13 \quad 12 = 21 \rightarrow 6.
\end{align*}
\]

In the case of cubic symmetry, we are seeking, by the transformation of the elements from the \(x_i\) to the new set, the GVM coefficients presented in eq. (17) and in table I. Thus we have the following results

\[
\begin{align*}
\rho_{11}' = \rho_{12}' = \rho_{33}' = \rho_0 & \quad (18) \\
\rho_{123}' = \rho_{231}' = \rho_{312}' = \rho_{123} & \quad (19) \\
\rho_{111}' = \rho_{122}' = \frac{1}{2}(\rho_{111} + \rho_{122} + 2 \rho_{1212}) & \quad (20) \\
\rho_{333}' = \rho_{111} & \quad (21) \\
\rho_{113}' = \rho_{223}' = \rho_{331}' = \rho_{332}' = \rho_{1122} & \quad (22) \\
\rho_{2211}' = \rho_{1222}' = \frac{1}{2}(\rho_{111} + \rho_{122} - 2 \rho_{1212}) & \quad (23) \\
\rho_{1212}' = \frac{1}{2}(\rho_{1111} + \rho_{1122}) & \quad (24) \\
\rho_{2323}' = \rho_{1313}' = \rho_{1212}' & \quad (25).
\end{align*}
\]

The difference between the cubic case, eqs. (18)-(25), and tetragonal symmetry, eq. (17) and table I, is obvious. The problem is thus reduced to the determination of the \(\rho_{ij}(\mathbf{B})\) from measurements of the \(\rho_{ij}(\mathbf{B})\), thereby to the deduction of the tetragonal environment in case of reduced symmetry. The procedure is as follows :

4.1 Specific Resistance and Hall Coefficient. — Using the method presented in 3.3.1-3.2, we measure \(\rho_{11}' = \rho_{33}' = \rho_0\) and \(\rho_{123}' = \rho_{231}' = \rho_{312}' = \rho_{123}\). In case the actual symmetry is tetragonal, however, \(\rho_{11}' \neq \rho_{33}'\). Thus by rotating the four contacts, a maximum in the ratio \(R_{11}/R_2\) can be found, thus determining the anisotropy ratio \(\lambda\). From eqs. (4) and (5), \(\rho_{11}'\) and \(\rho_{33}'\) are determined and the directions of the \(x_1', x_3\) axes are defined. In this manner, the reduced symmetry is revealed and evaluated. It should also be mentioned that the measurement of the Hall coefficient with perpendicular magnetic field \(\mathbf{B} = (0, B, 0)\) yields the coefficient \(\rho_{231}' = \rho_{312}'\).

4.2 WFMR Coefficients. — In the case of \(\mathbf{B} = (B_x, B_y, B_z)\) and \(\mathbf{J} = (J_x, 0, J_y)\) (referred to the primed coordinate system), the anisotropy that appears has principal axes which, in general, are different from the \(x'_1\) and \(x_3'\) axes. For cubic symmetry, the measurement of \(\rho_{122}, \rho_{331}(= \rho_{113}),\) and \(\rho_{333}\) allows the determination of \(\rho_{1111}, \rho_{1122},\) and \(\rho_{1212}\) from the relations (21), (22) and (23). Thus

\[ a) \text{ For } \mathbf{B} = (0, B, 0) \text{ (that is, perpendicular to the sample plane) we have}
\]

\[
\rho(\mathbf{B}) = [\rho_{11}' + \rho_{1122}' B^2] p_3^2 + [\rho_{33}' + \rho_{331}' B^2] r^2,
\]

and

\[
\Delta \rho = \rho_{1122}' B^2 p_3^2 + \rho_{331}' B^2 r^2 = \Delta \rho_{11}' p_3^2 + \Delta \rho_{33} r^2 ,\tag{27}
\]

where

\[
\Delta \rho_{11}' = \rho_{11}'(\mathbf{B}) - \rho_{11}', \quad \Delta \rho_{33} = \rho_{33}'(\mathbf{B}) - \rho_{33}' .\tag{28}
\]

This leads to

\[
\rho_{1122}' = \frac{\Delta \rho_{11}'}{B^2} \quad \text{and} \quad \rho_{331}' = \frac{\Delta \rho_{33}'}{B^2} .\tag{29}
\]
b) For $\vec{B}(0, 0, B)$ we have
\[
\rho(\vec{B}) = \left[ \rho'_{11} + \rho'_{1133} B^2 \right] p^2 + \left[ \rho'_{33} + \rho'_{3333} B^2 \right] B^2,
\]
which leads to
\[
\rho'_{1133} = \frac{\Delta \rho'_{11}}{B^2} \quad \text{and} \quad \rho'_{3333} = \frac{\Delta \rho'_{33}}{B^2}.
\]

The case of reduced, tetragonal symmetry is immediately apparent from these measurements if we find that
\[
\rho'_{3311} \neq \rho'_{1133}.
\]

### 5. Sample parallel to the (111) plane.

In many instances we deal with material that cleaves along the (111) plane. As in the previous section, we should again choose a sample-oriented coordinate system in terms of which the tensor elements are more conveniently defined and measured. As a new frame of reference we choose the axes $[110] = x_1$, $[112] = x_2$, and $[111] = x_3$ perpendicular to the (111) plane (Fig. 6) as in [2] and [5]. The $x_1$, $x_2$ and $x_3$ directions coincide with the two-fold axis, the bisectrix and the three-fold axis, respectively, of trigonal crystals [C3v, (3m) and D3d(3m) groups].

The nonzero elements of the resistivity and Hall tensors for these groups are [1, 13]
\[
\rho_{11} = \rho_{22}, \quad \rho_{33}, \quad \rho_{123} \quad \text{and} \quad \rho_{231} = \rho_{312},
\]

and
\[
\rho_{11} = \frac{\Delta \rho'_{11}}{B^2} \quad \text{and} \quad \rho_{3333} = \frac{\Delta \rho'_{33}}{B^2}.
\]

The nonzero WFMR coefficients for the groups C3v and D3d are given in Table II with the following correspondence:

<table>
<thead>
<tr>
<th>$B_1^2$</th>
<th>$B_2^2$</th>
<th>$B_3^2$</th>
<th>$B_4$</th>
<th>$B_5$</th>
<th>$B_6$</th>
</tr>
</thead>
<tbody>
<tr>
<td>$E_1$</td>
<td>$J_1$</td>
<td>$J_2$</td>
<td>$J_3$</td>
<td>$J_4$</td>
<td>$J_5$</td>
</tr>
</tbody>
</table>

Returning now to the cubic case. With the transformation from the $x_i$ to the $x'_i$ coordinates we are seeking the GVM coefficients of eq. (33) and Table II. Thus we have the following results
\[
\rho'_{11} = \rho'_{22} = \rho'_{33} = \rho_0,
\]
\[
\rho'_{123} = \rho'_{231} = \rho'_{312} = \rho_{123},
\]
\[
\rho'_{3311} = \frac{\Delta \rho'_{33}}{B^2}.
\]

The difference between cubic and trigonal symmetry is obvious from a comparison of eqs. (34)-(42) with eq. (33) and Table II. The problem is again reduced to the determination of the $\rho_{ij}(\vec{B})$ by measuring the $\rho_{ijk}(\vec{B})$ and, in case of reduced symmetry, of determining the trigonal environment. The procedure to be followed is outlined below.

#### 5.1 Specific resistance and Hall coefficient.

By using the method presented in 3.1-3.2, we measure the $\rho_{11} = \rho_{22} = \rho_0$ and $\rho_{123} = \rho_{123}$. If there is an environment of trigonal symmetry it cannot be detected here, since on a specimen with faces parallel to the $(x_1', x_2') \,[=\,(111)]$ plane, the measurements of $\rho_{22}$ and $\rho_{223}$ are impossible.

#### 5.2 WFMR coefficients.

If $\vec{B} = (Bu, Bv, Bw)$ and $\vec{J} = (Jp, Jq, 0)$ (in the primed system of reference), the resistivity anisotropy will appear with the principal axes different from the $x_1'$ and $x_2'$ directions. For cubic symmetry the measurement of $\rho'_{1111}, \rho'_{2222}, \rho_{1133}$ allows the determination of $\rho_{1111}, \rho_{2222}, \rho_{1133}$ from the relations (36), (38) and (39). Now we consider the specific cases

![Fig. 6. The coordinate system in the case of a sample parallel to the (111) plane.](image-url)
that is, the anisotropy axes are $x'_1$ and $x'_2$, so that

$$
\Delta \rho = \rho_{1111} B^2 p^2 + \rho'_{1222} B^2 q^2 = \Delta \rho_{11} p^2 + \Delta \rho_{22} q^2,
$$

where

$$
\Delta \rho_{11} = \rho'_{11}(B) \rho_{1111} - \rho_{1111} \rho_{11}''(B)
$$

and

$$
\Delta \rho_{22} = \rho'_{22}(B) \rho_{1111} - \rho_{1111} \rho''_{22}(B),
$$

Therefore

$$
\rho'_{1111} = \frac{\Delta \rho_{11}}{B^2} \quad \text{and} \quad \rho'_{1122} = \frac{\Delta \rho_{22}}{B^2}.
$$

6. Discussion and conclusions. — In this paper we have summarized the procedures for determining the WFMR coefficients in the case of cubically symmetric environments, by using the Van der Pauw experimental arrangement. Thus a reliable set of data may be obtained which allows to distinguish different environments in the case of (001), (110) and (111) oriented surface layers, revealing possible position dependent or structural anisotropies, and also allowing to follow phase transformations.

The analysis presented here is more advantageous or complementary with the classical one, based on the Seitz-Pearson-Suhl (SPS) formulation. This last procedure may prove in some cases difficult or impossible to apply. This is because in our case the current density $J$ does not need to be in any particular direction, while in the classical experimental configuration only specific directions can be used and this in the case of specific crystallographic environments e.g. the SPS formulation does not apply in cases of reduced symmetry. Thus with the classical configuration only four WFMR coefficients can be determined, while with the proposed procedure the number is increased e.g. in the case of orthorhombic symmetry from one sample seven different WFMR coefficients are determined. The advantage is obvious because elements concerning the band structure of the material may be calculated, such as the effective masses, the constants of the relaxation times and also the angle $\theta$ which defines the arrangement of the energy ellipsoids in $k$ space in a selfconsistant way.

Finally with this method the results have more physical sense i.e. in the case of the polar plots of $\rho(0)$ and $\rho(B)$ (eqs. (7) and (8)). Thus the influence of the magnetic field in inducing resistance anisotropy is immediately apparent.

In conclusion we may say that the experimental method presented here is more simple and the results obtained are more informative. Application of this method to investigate the transformation of SnTe and GeSnTe and to define the environment after the transformation, which is a debated subject, is under consideration.

Appendix. Derivation of equation (15). — Referring to figure 4, the transformation matrix in the new axes $x'_1$, $x'_2$, and $x'_3$, is

$$
[x'_i] = \begin{pmatrix}
\cos \phi & -\sin \phi & 0 \\
\sin \phi & \cos \phi & 0 \\
0 & 0 & 1
\end{pmatrix}.
$$

where now the $\rho''_{ij}(B)$ are along the new axes of anisotropy.

Since we have already determined $\rho'_{1111}$, $\rho'_{1122}$ and $\rho'_{1133}$, eqs. (50), (51) and (52) identify three possible methods to measure $\rho_{1123}$. The experimental procedure is similar to that presented in 3.3 b. To simplify matters, we may choose all the angles 45° so that $u = 1/2$, $v = 1/2$, $w = 1/\sqrt{2}$.

$$
\begin{align*}
\text{a) } & \vec{B} = (B, 0, 0). \text{ Then } \\
\rho(\vec{B}) &= (\rho_{11} + \rho_{1111} B^2) p^2 + (\rho_{22} + \rho_{1122} B^2) q^2; \\
\text{b) } & \vec{B} = (0, 0, B). \text{ Then } \\
\rho(\vec{B}) &= (\rho_{11} + \rho_{1133} B^2) p^2 + (\rho_{22} + \rho_{1123} B^2) q^2 + (\rho_{23} + \rho_{1132} B^2) w^2; \\
\text{c) If the symmetry is cubic, then six different magnitudes are involved in the WFMR coefficients, eqs. (36) to (40) (only three are independent), while in the case of trigonal symmetry eight become independent, with the new inequalities } \rho_{2311} \neq \rho_{1133} \text{ and } \rho_{2311} \neq \rho_{1123}. \text{ Therefore by calculating a fourth coefficient, e.g. the } \rho_{1123} \text{ from the relation (41), using } \rho_{1111}, \rho_{1122} \text{ and } \rho_{1123}, \text{ and then measuring experimentally the } \rho_{1123}, \text{ we have a way of distinguishing the two environments [2, 5].}
\end{align*}
$$

To measure the $\rho_{1123}$, we use $\vec{B} = (B u, B v, B w)$. As in 3.3 b) the anisotropy axes form an angle $\phi$ with $x'_1$ and $x'_2$. Thus

$$
\Delta \rho = [\rho'_{11}(\vec{B}) \cos^2 \phi + \rho'_{22}(\vec{B}) \sin^2 \phi - \rho_{11}'] p^2 + [\rho'_{11}(\vec{B}) \sin^2 \phi + \rho'_{22}(\vec{B}) \cos^2 \phi - \rho_{22}'] q^2 + [\rho'_{11}(\vec{B}) \sin 2 \phi - \rho'_{22}(\vec{B}) \rho_{11}'] p q.
$$

In this case the following equations are valid

$$
\begin{align*}
(\rho_{1111} u^2 + \rho_{1122} v^2 + \rho_{1133} w^2 + 2 \rho_{1123} u v w) B^2 &= \\
= \rho_{11}(\vec{B}) \cos^2 \phi + \rho_{22}(\vec{B}) \sin^2 \phi - \rho_{11},
\end{align*}
$$

and

$$
2 [2 \rho_{1123} u w + (\rho_{1111} - \rho_{1122}) u v] B^2 = \\
= \sin 2 \phi [\rho''_{11}(\vec{B}) - \rho''_{22}(\vec{B})].
$$
and thus the tensor element \( [\rho_{ij}(B)] \) in the unprimed coordinate system is obtained from the relation

\[
[\rho_{ij}(B)] = [x_k] [\rho^t_{kl}(B)] [x_l]^t, \quad (A.2)
\]

where \([x_k]^t\) is the transpose matrix of \([x_k]\). From this relation we have

\[
[\rho_{ij}(B)] = \begin{pmatrix}
\cos^2 \varphi \rho'_{11}(B) + \sin^2 \varphi \rho'_{22}(B) & 2 \sin \varphi [\rho'_{11}(B) - \rho'_{22}(B)] & 0 \\
\frac{1}{2} \sin 2 \varphi [\rho'_{11}(B) - \rho'_{22}(B)] & \sin^2 \varphi \rho'_{11}(B) + \cos^2 \varphi \rho'_{22}(B) & 0 \\
0 & 0 & \rho_{33}(B)
\end{pmatrix} \quad (A.3)
\]

where \(\rho'_{11}(B)\) and \(\rho'_{22}(B)\) are the principal resistivities along the \(x'_1\) and \(x'_2\) axes respectively. The resistivity in the direction of \(J\) in the presence of the field is

\[
\rho(B) = \rho'_0 \cos \omega, \quad \rho_0 = \begin{pmatrix}
\rho'_{11}(B) \cos^2 \varphi + \rho'_{22}(B) \sin^2 \varphi & \rho'_{11}(B) \sin^2 \varphi + \rho'_{22}(B) \cos^2 \varphi & 2 \frac{1}{2} \sin 2 \varphi \rho'_{11}(B) - \rho'_{22}(B)
\end{pmatrix} \cos \omega \sin \omega \quad (A.4)
\]

Comparing eqs. (8) and (A.4) with \(p = \cos \omega, \varphi = \sin \omega \) and \(r = 0\) the following equations are obtained

\[
\rho_0 + (\rho_{1111}u^2 + \rho_{1122}v^2)B^2 = \rho'_{11}(B) \cos^2 \varphi + \rho'_{22}(B) \sin^2 \varphi \quad (A.5)
\]

\[
4 \rho_{1212} B^2 = \frac{1}{2} \sin 2 \varphi \rho'_{11}(B) - \rho'_{22}(B) \quad (A.6)
\]

In a similar manner eqs. (50), (51) and (52) can be obtained for the case of a sample parallel to (111) plane.

References